

Form PTO 1449 (Rev. 2-32)				U.S. Department of Commerce Patent and Trademark Office		Atty. Docket No. 034299-617		Serial No. 10/520,647	
Information Disclosure Statement by Applicant						Applicant: Marie D'Angelo, et al.			
(Use several sheets if necessary)						Filed: January 5, 2005		Group: (to be assigned)	
U.S. Patent Documents									
Init.		Document No.	Date	Name	Class	Subclass	Filing Date		
TC/	A	US2004/0132242	7/8/04	D'Angelo et al.					
	B	3,998,662	12/21/76	Anthony et al.					
	C	4,735,921	4/5/88	Soukiassian					
	D	4,900,710	2/13/90	Soukiassian et al.					
	E	6,274,234	8/14/01	Dujardin et al.					
	F	6,667,102	12/23/03	Amy et al.					
Foreign Documents									
Init.		Document No.	Date	Country	Class	Subclass	Translation		
TC/	G	2 757 183	12/16/96	France			Yes	No	
TC/	H	2 786 794	12/2/98	France (w/English Abstract)				X	
Other Documents (Including Author, Title, Date, Pertinent Pages, etc.)									
TC/	I	Crommie, M.F. et al., "Waves on a Metal Surface and Quantum Corrals", <i>Surface Review and Letters</i> , Vol. 2, No. 1, pages 127-137 (1995)							
	J	Franciosi, A. et al., "Electronic promoters and semiconductor oxidation: Alkali metals on Si(111) surfaces", <i>Physical Review B</i> , Vol. 35, No. 2, pages 910-913 (1987)							
	K	Gentle, T. M., "CH ₃ Cl Adsorption on a Si(100)2 X 1 Surface Modified by Alkali Metal Overlayer Studied by Soft X-Ray Photoemission Using Synchrotron Radiation", <i>Surface Science Letters</i> 202, pages 568-576 (1988)							
	L	Huttel, Y. et al., "Al ₂ O ₃ /Al interface formation by promoted oxidation using an alkali metal and removal of the catalyst", <i>Applied Physics Letters</i> 62, pages 2437-2439 (1993)							
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	P	Soukiassian, P., et al., "Catalytic Nitridation of a III-V Semiconductor Using Alkali Metal", <i>Europhysics Letters</i> 12, pages 87-92 (1990)							
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Examiner					Date Considered				
/Tsz Chiu/ (10/01/2007)					10/01/2007				
Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include a copy of this form with the next communication to applicant.									

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